



Low-Temperature, High Throughput Process for Thin, Large-Grained Poly Si: Final Technical Report (Paperback)

By National Renewable Energy Laboratory (NREL)

Bibliogov, United States, 2012. Paperback. Book Condition: New. 246 x 189 mm. Language: English . Brand New Book ****** Print on Demand *****. The overall project goal is to understand the fundamental gas phase, and surface and interface science issues relevant to low-temperature (T less than 600oC) synthesis of polycrystalline silicon films on low-cost (e.g., glass) substrates. This understanding will be used to delineate the path to break through existing barriers to high-rate synthesis of high-quality thin films for polycrystalline silicon photovoltaic applications. In this context, high quality P refers to large grain size (greater than film thickness) and long (greater than film thickness) minority-carrier diffusion length.



Reviews

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